APPLICATION DATA SHEET

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Title of Invention:

METHOD OF FABRICATING SEMICONDUCTOR DEVICE HAVING

GROUP III NITRIDE

Legal Representative:

Attorney or Agent:

Donald R. Studebaker

Registration Number:

32815

Continuity Data:

This application is a reexamination of 09/389,024 A1 1999-09-02 6,117,700 A1 2000-09-12

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